Introduction

The Second OIML Certification System (OIML-CS) Management Committee Meeting and associated events took place in March 2019 at the new premises of NMi in Delft, Netherlands.

Review Committee

A meeting of the Review Committee (RC) was held during the morning of 19 March. The RC is responsible for making recommendations to the Management Committee on the approval of applications from OIML Issuing Authorities (IAs), Test Laboratories (TLs), Legal Metrology Experts and Management System Experts. At the meeting a number of applications for OIML IAs, TLs and experts were reviewed and positive recommendations on approval were made. There were also discussions on the operation of the RC, the monitoring of applications approved with conditions and the level of evidence that should be supplied to support applications from experts.

Maintenance Group

The Maintenance Group (MG), which is responsible for the maintenance and development of the documentation associated with the operation of the OIML-CS, held its second meeting on the afternoon of 19 March. At the meeting, the MG discussed items relating to the OIML-CS and the potential impact on the documentation. This resulted in a number of recommendations being made to the Management Committee for consideration at its meeting, including:

- use of test data from field-sites;
- interpretation of the use of test reports by an OIML IA from a TL of another OIML IA;
- role of the MC in a potential amended review/revision process for OIML Recommendations;
- development of a clarifications/interpretation document.

ISO/IEC 17065 Working Group

The MG meeting was followed by a first meeting of the Working Group (WG) that is responsible for reviewing the application of ISO/IEC 17065 to the assessment of competence of OIML IAs. The WG identified ISO/IEC 17020 as a potential alternative and considered that a gap analysis between the two standards should be conducted. In addition, the WG proposed that it should try to identify other potential alternative approaches.

Management Committee

The Second Management Committee Meeting was held on 20–21 March and was attended by 42 representatives from 18 countries (Australia, Belgium, Cambodia, Canada, Colombia, Czech Republic, France, Germany, India, Japan, Netherlands, P.R. China, Russian Federation, Slovakia, South Africa, Switzerland, United Kingdom and United States). In addition, five organisations in liaison (AQUA, CECIP, CE COD, IAF and ILAC) were represented, and a representative from the IEC also participated in a part of the meeting via video link.

Over the course of the two days, there were discussions on a number of key items including the outcomes of the RC, MG and WG meetings held prior to the MC meeting. Some of the key items under consideration were:

- review of OIML IA annual reports;
- assessment requirements for OIML IAs and TLs and how the OIML-CS could benefit from the approaches adopted by other certification systems, e.g. the IECEx Certified Equipment Scheme;
- use and monitoring of experts in assessments;
- application of ISO/IEC 17065 for the assessment of OIML IA competence;
- conformity marks and limiting the validity of certificates;
- extension of the transition period for OIML IAs to use self-declaration;
- use of test data from field-sites;
- promotion and awareness raising.
During the meeting, the MC approved a number of applications from OIML Issuing Authorities and their associated Test Laboratories, Legal Metrology Experts and Management System Experts based on the positive recommendations from the RC. The MC decided that the WG for ISO/IEC 17065 should explore alternative approaches, e.g. the possible use of ISO/IEC 17020, and should also take into consideration the possible impact of Conformity to Type (CTT) should a CTT system be implemented in the OIML-CS in the future.

The MC agreed that a conformity (certification) mark should not be implemented as the OIML-CS does not include CTT. However, this will be reviewed should a CTT system be implemented in the OIML-CS in the future. The MC also agreed that it would participate in any new amended review/revision process for OIML Recommendations that are of relevance to the OIML-CS.

Two new Working Groups were established by the MC; one to make proposals relating to the assessment requirements for OIML Issuing Authorities and Test Laboratories and the other to improve promotion and awareness raising.

**Euroloop visit**

Following the MC meeting, there was a visit to the Euroloop calibration facility on 22 March. A presentation on the work of Euroloop was given, followed by a tour of the facility.

**Next MC Meeting**

The Third OIML-CS MC Meeting and associated events will be held in New Delhi, India during the week commencing 16 March 2020.

Further information on the OIML-CS is available on the OIML website at:

https://www.oiml.org/en/oiml-cs/general-info

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